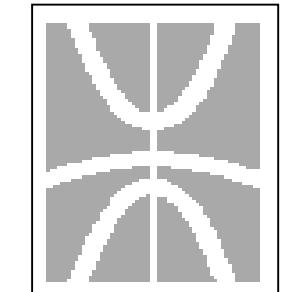


Ultraviolet Laser Source Based on Nonlinearly Frequency-Converted Copper and Copper Bromide Vapor Laser Systems



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INTRODUCTION

Precise micromachining with laser ablation requires ultraviolet or deep ultraviolet (UV and DUV) laser radiation, since the processed area size after focusing linearly depends on the laser radiation wavelength. In addition to the high resolution, the UV and DUV laser radiations have sufficiently high enough photon energy to induce some phenomena in different materials, such as material and its surface modification, fluorescence, image recording, etc. Nonlinear frequency conversion is a well-known method for oscillating in the UV and DUV spectral ranges. Several UV and DUV laser sources have been well developed and investigated, such as frequency-quadrupled and frequency-tripled Nd:YAG and Nd:YLF lasers, frequency-doubled argon ion lasers, and frequency-doubled dye lasers.

UV laser sources based on nonlinear frequency conversion of copper vapor laser (CVL) radiation at high pulse recurrence frequency (5-20 kHz) is quite competitive alternative. CVLs operate at the atomic copper 510.6- and 578.2-nm lines. UV radiation at 255.3 nm, 289.1 nm and 271.2 nm has been generated in various nonlinear crystals, namely Potassium Dihydrogen Phosphate (KDP), β -barium borate (BBO) and cesium lithium borate (CLBO) by frequency doubling the 510.6-nm and 578.2-nm output and sum-frequency generation of the two laser lines. Applying spherical optics for the laser beam focusing in a β -barium borate (BBO) nonlinear crystal, the maximal DUV laser power at the 255.3-nm laser line has been 450 mW through frequency doubling the 510.6-nm output (T. S. Petrov et al). Utilizing cylindrical optics instead of spherical ones to reduce the hazard of nonlinear crystal damage at high average pump laser power (M. J. Withford et al; D. J. W. Brown et al), the DUV laser power has been consecutively increased from 1.3 W (M. J. Withford et al) to 3 W via nonlinear BBO crystals (D. J. W. Brown et al) and up to 15 W with a nonlinear crystal made of CLBO (D. J. W. Brown et al).

AIM

To develop and study a reliable laser source, which operates at the DUV laser lines of 255.3 nm, 289.1 nm and 271.2 nm by frequency conversion of MO-PA Cu (CuBr) vapor system output in BBO and KDP nonlinear crystals using spherical optics.

EXPERIMENTAL SETUP

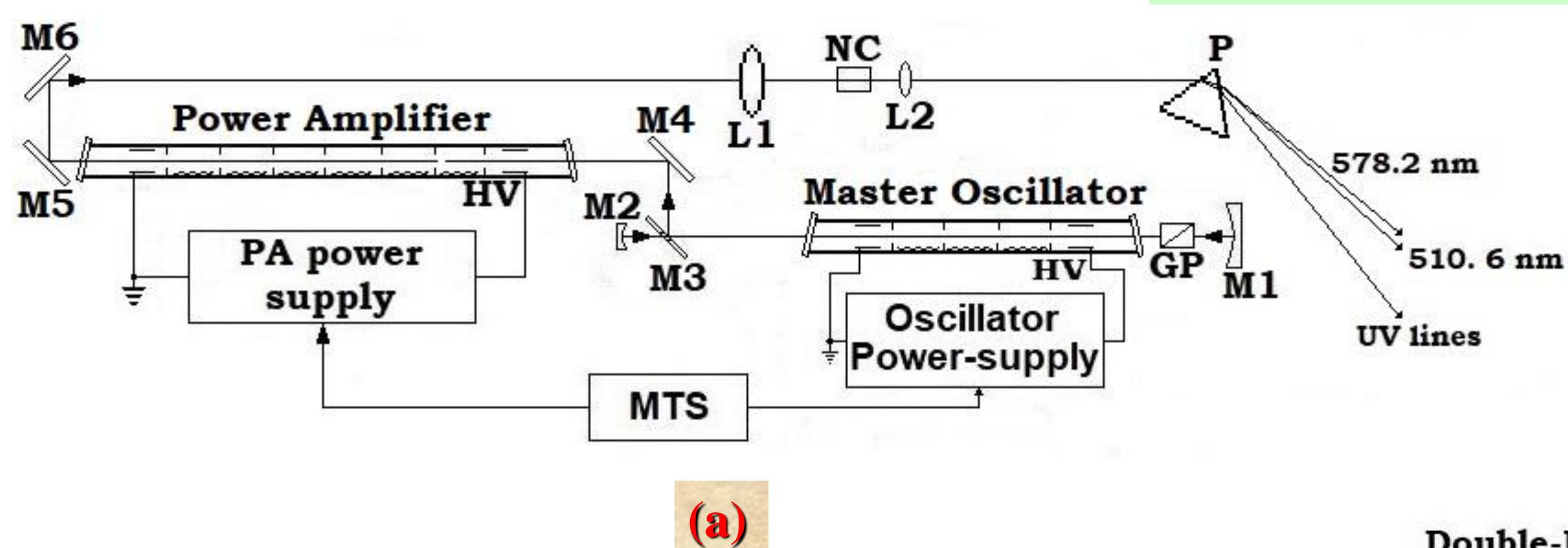
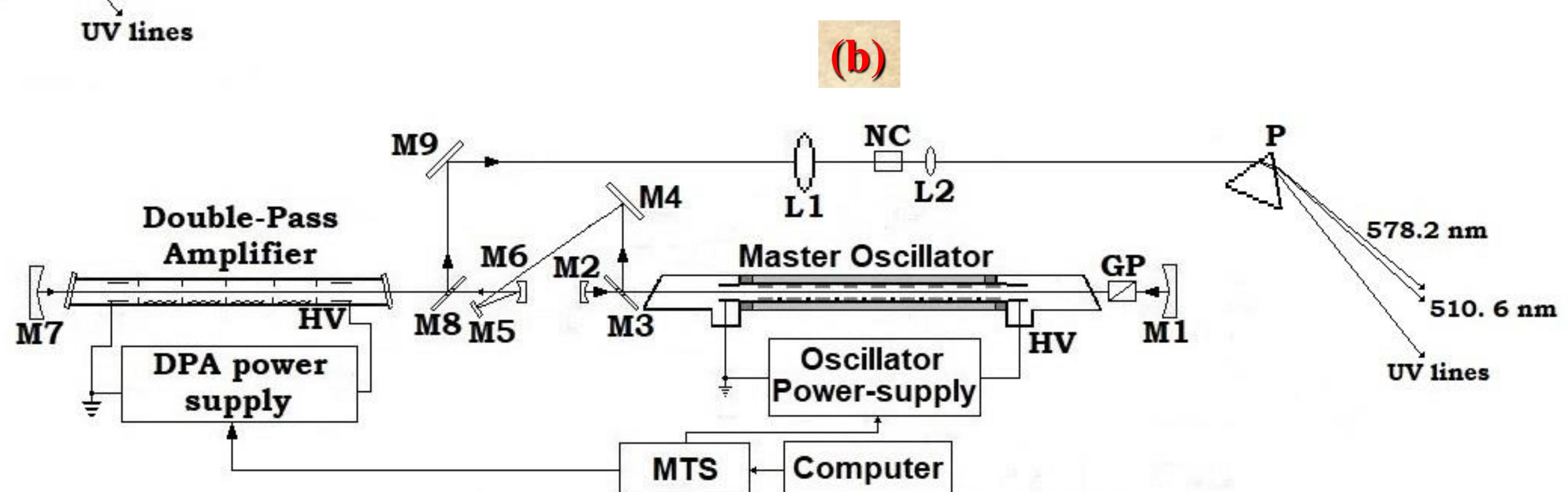


Table 1. Parameters of optical elements.

MO	Optics	M1	M2	M3	M4	M5	M6	M7	M8	M9	L1	L2
(a)	Focal length (cm)	115	2.5	∞	0.5-mm orifice	∞	∞	∞	—	—	100	15
(b)	Focal length (cm)	115	5.0	∞	0.5-mm orifice	∞	∞	50	250	∞	100	15

Fig. 1. Schematic diagram of studied MO-PA CuBr vapor (a) and MO Cu vapor - DPA CuBr vapor (b) systems.



EXPERIMENTAL RESULTS

Table 2. Summary of our frequency conversion results with maximal UV average laser power and maximal conversion efficiency: λ_p – pump laser wavelength; λ_G – nonlinearly converted wavelength; D – laser beam diameter; f – focusing distance; f/D – focusing number; P_{out}^{pump} – average pump power at 510.6 nm, 578.2 nm and total average pump power at multiline laser oscillation; P_{out}^{UV} – ultraviolet average power; η – conversion efficiency.

Master Oscillator			Power Amplifier			Important Characteristics								
d_a (mm)	l_a (cm)	V_a (cm 3)	d_a (mm)	l_a (cm)	V_a (cm 3)	Nonlinear crystal	λ_p (nm)	λ_G (nm)	D (mm)	f (cm)	f/D	P_{out}^{pump} (W)	P_{out}^{UV} (mW)	η (%)
20	50	157.1	20	50	157.1	15-mm BBO	510.6	255.3	18	75	42	7.20	1610	22.36
20	50	157.1				15-mm BBO	510.6	255.3	18	100	56	10.00	1255	12.55
20	50	157.1				15-mm BBO	510.6	255.3	8 / 18	75	94 / 42	1.00	152	15.20
20	50	157.1				15-mm BBO	510.6	255.3	6 / 18	75	125 / 42	4.80	1369	28.52
20	50	157.1	11	63	59.9	15-mm BBO	510.6	255.3	10	40	40	3.00	916	30.53
20	50	157.1	11	63	59.9	15-mm BBO	510.6	255.3	4 / 10	40	100 / 40	4.55	1060	23.30
20	50	157.1	11	63	59.9	15-mm BBO	510.6	255.3	4 / 10	40	100 / 40	0.23	63	27.39
20	50	157.1	11	63	59.9	15-mm BBO	510.6	255.3	4 / 10	40	100 / 40	1.67	515	30.84
20	50	157.1	15	63	111.3	15-mm BBO	510.6	255.3	14	100	71	0.52	191	36.64
3	30	2.1	15	63	111.3	15-mm BBO	510.6	255.3	14	40	29	8.00	1060	13.25
3	30	2.1	15	63	111.3	15-mm BBO	510.6	255.3	14	100	71	5.50	766	13.93
3	30	2.1	15	63	111.3	15-mm BBO	510.6	255.3	8	20	25	5.40	615	11.39
3	30	2.1	15	63	111.3	15-mm BBO	510.6	255.3	6	20	33	5.00	586	11.72
3	30	2.1	15	63	111.3	15-mm BBO	510.6	255.3	6	20	33	1.47	353	24.01
3	30	2.1	15	63	111.3	15-mm BBO	510.6	255.3	6	20	33	1.15	310	26.96
3	30	2.1	15	63	111.3	5-mm BBO	510.6	255.3	6	20	33	0.81	162	20.00
20	50	157.1	20	100	314.2	20-mm KDP	510.6	271.2	18	100	56	0.75	151	20.13
20	50	157.1	20	100	314.2	20-mm KDP	578.2	289.1	18	100	56	7.00	483	6.90
20	50	157.1	20	100	314.2	20-mm KDP	578.2	289.1	18	100	56	3.50	251	7.17

CONCLUSIONS

Най-високата средна лазерна мощност на линията 255.3 nm е 1.6 W при средна напомпваща мощност 7.20 W, т. е. ефективността на честотното преобразуване е 22.2 %, докато максимална ефективност на честотно преобразуване 34.3 % се достига при средна УВ лазерна мощност 144 mW и средна мощност на напомпване 0.40 W.

Acknowledgements: This work was supported by the Project KP-06-H77/8 "Development and basic research of high-beam-quality laser system oscillating in ultraviolet spectral range" of Bulgarian National Science Fund.